

Supporting Information

Modifying the 316L Stainless Steel Surface by Electrodeposition Technique: Towards High-Performance Electrodes for Alkaline Water Electrolysis

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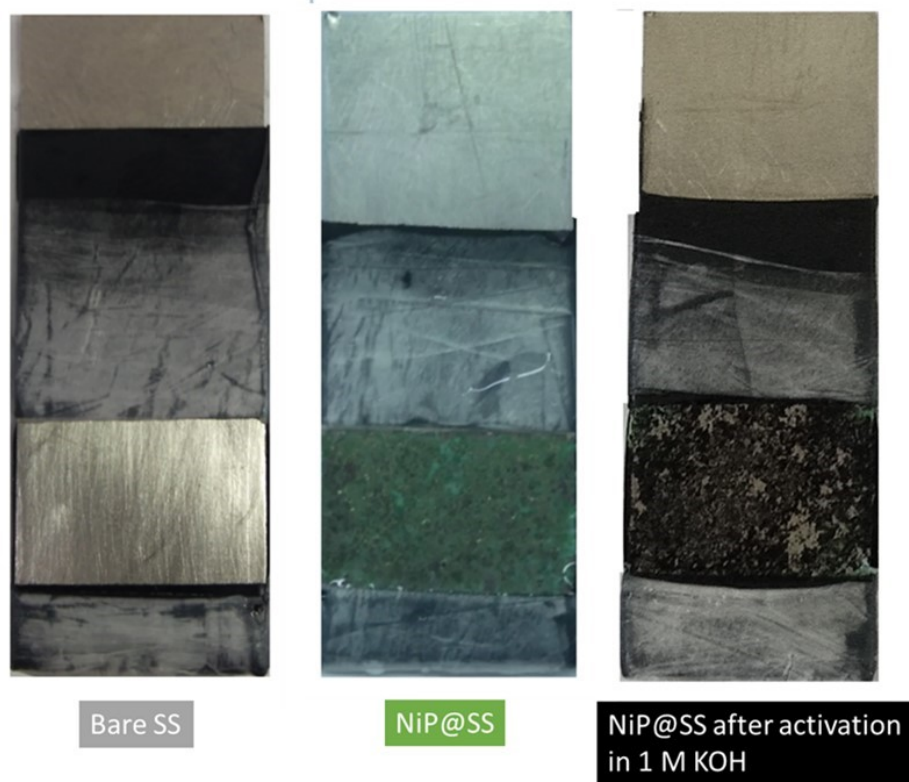


Fig. S1. Photos of SS: left before NiP electrodeposition, middle after x NiP electrodeposition, and right after activation of x NiP in 1.0M KOH.

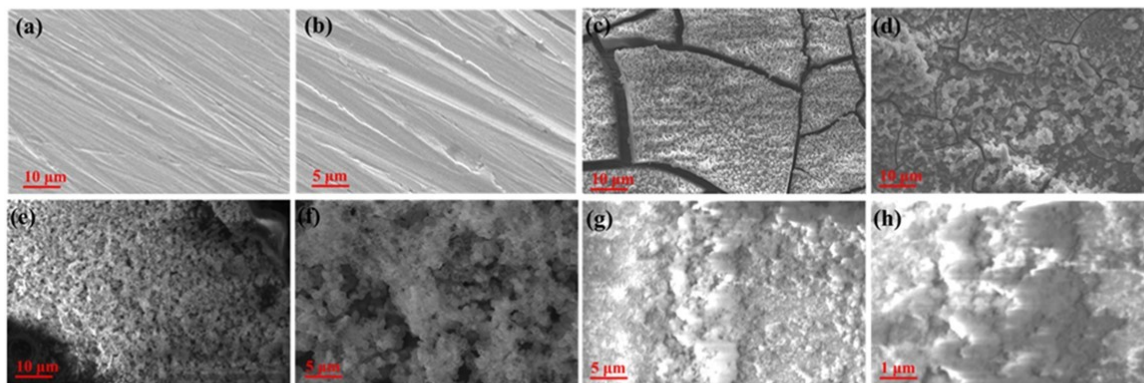


Fig. S2. SEM images of bare SS (a and b); $x\text{NiP}@SS$ electrodes at different deposition times c) 5 min, d) 10 min, and e-f) 15 min; g-h) SEM images of $\text{Ni}@SS$ electrode at 15 min.

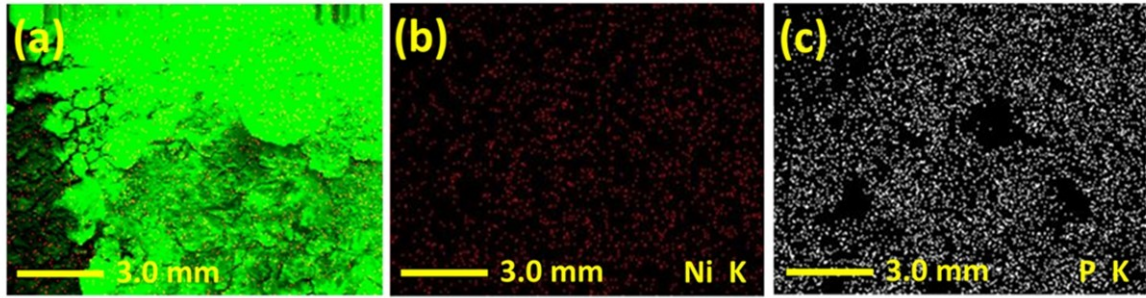


Fig. S3. SEM-EDX elemental mapping of 15NiP@SS electrode.

Table S1: Elemental analysis of $x\text{NiP}@SS$ nanoparticles determined by EDX analysis

Catalyst	Averaged atomic % (EDS)	
	Ni	P
@ Shortest deposition time (5NiP@SS)	51.94	48.06
@ Longest deposition time (20NiP@SS)	52.745	47.255

Video S1. The deposition process of $x\text{NiP}$ on SS surface at -20 mA cm^{-2} .

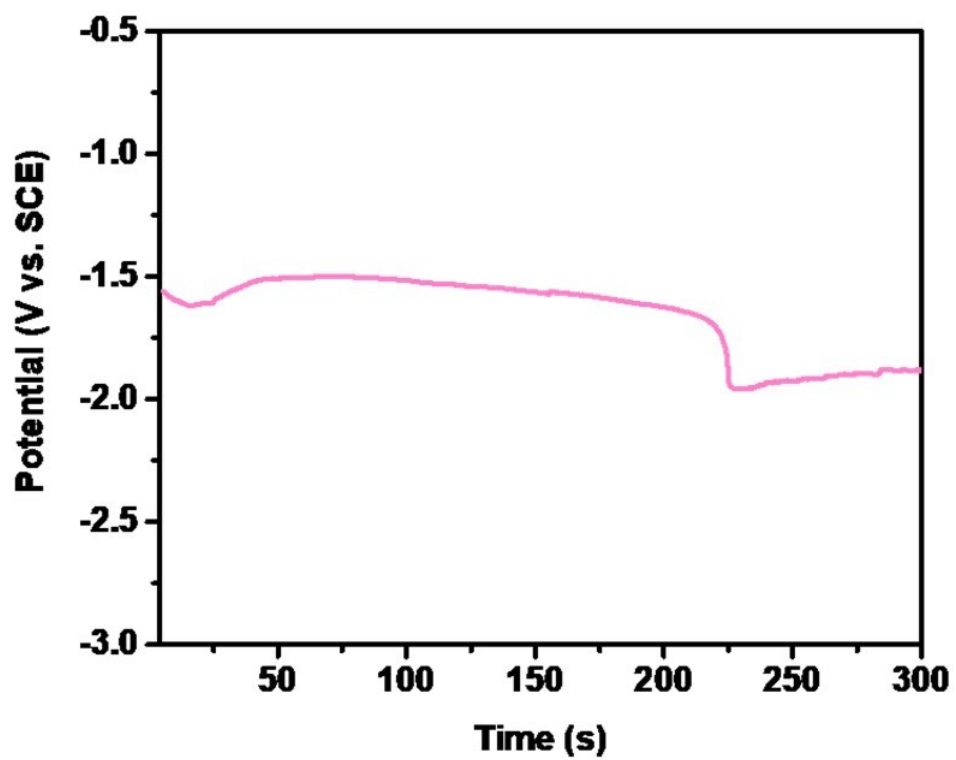


Fig. S4. The time-potential curve for the deposition process.

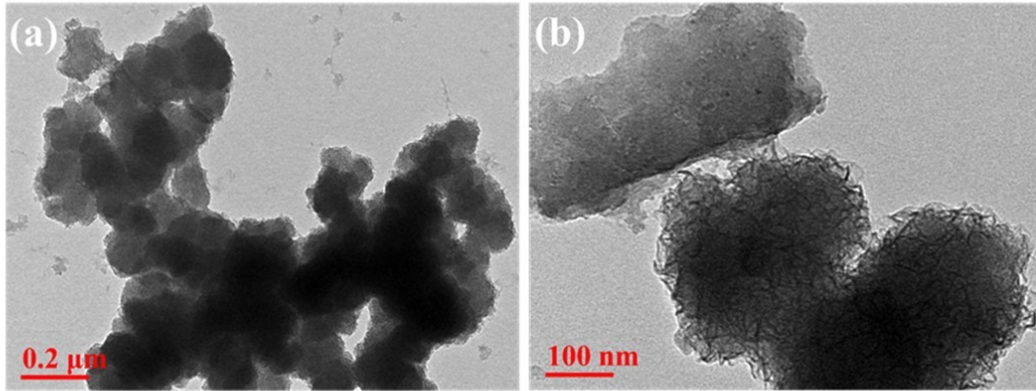


Fig. S5. (a) Low-magnification and (b) high-magnification TEM images of 15NiP@SS.

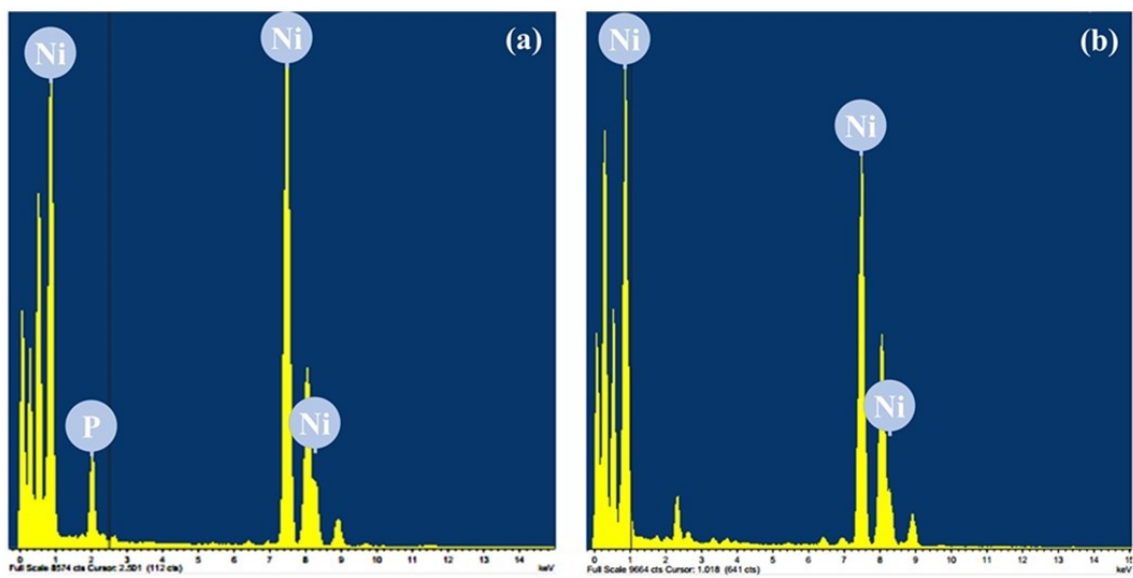


Fig.S6. The TEM-EDX images of 15NiP@SS (a) and Ni@SS (b).

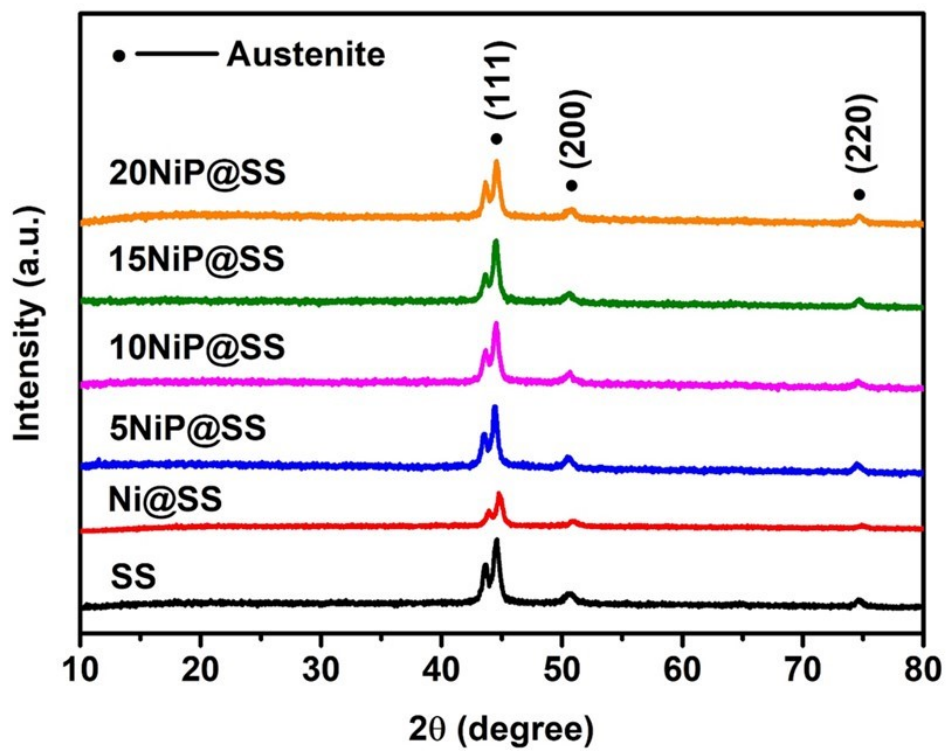


Fig. S7. XRD pattern of bare SS, Ni@SS, 5NiP@SS, 10NiP@SS, 15NiP@SS, and 20NiP@SS samples.

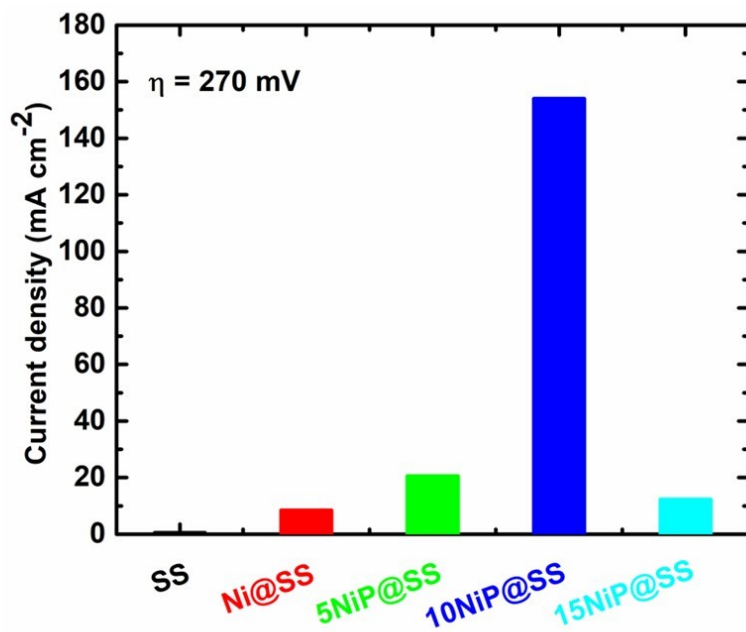


Fig. S8. Current densities of OER for all prepared catalysts at an overpotential of 270 mV

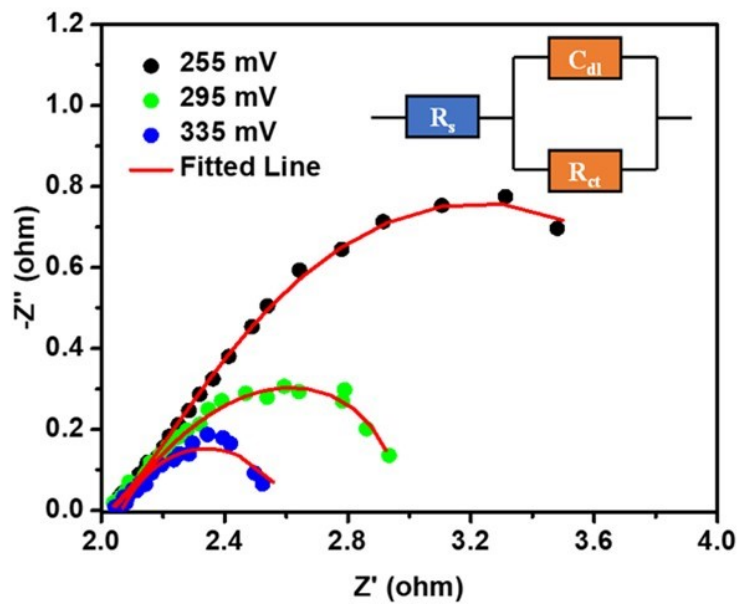


Fig. S9. Nyquist plots of 10NiP@SS recorded at increasing the overpotentials of OER over frequency range of 100 kHz to 100 mHz in 1 M KOH.

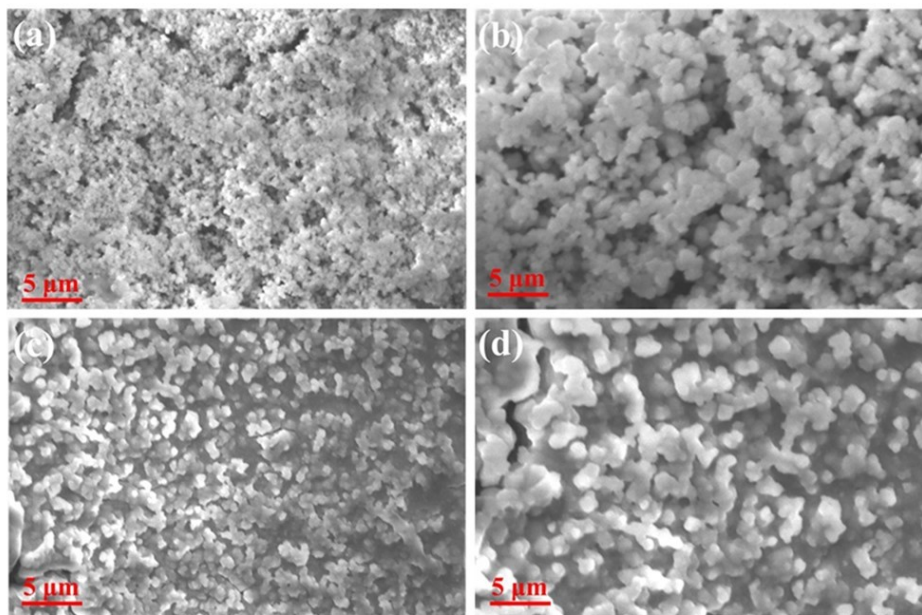


Fig. S10. SEM images of 10NiP@SS (a and b) after activation in 1 M KOH solution and (c and d) after OER stability for 24h

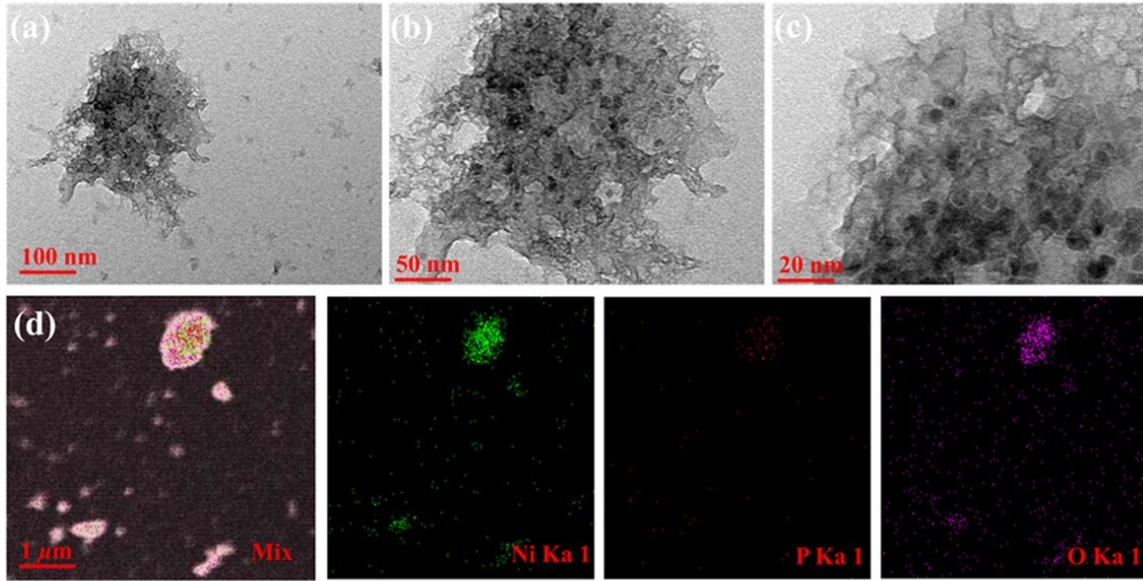


Fig. S 11. TEM images (a-c) and elemental mapping (d) of 10NiP@SS after KOH activation.

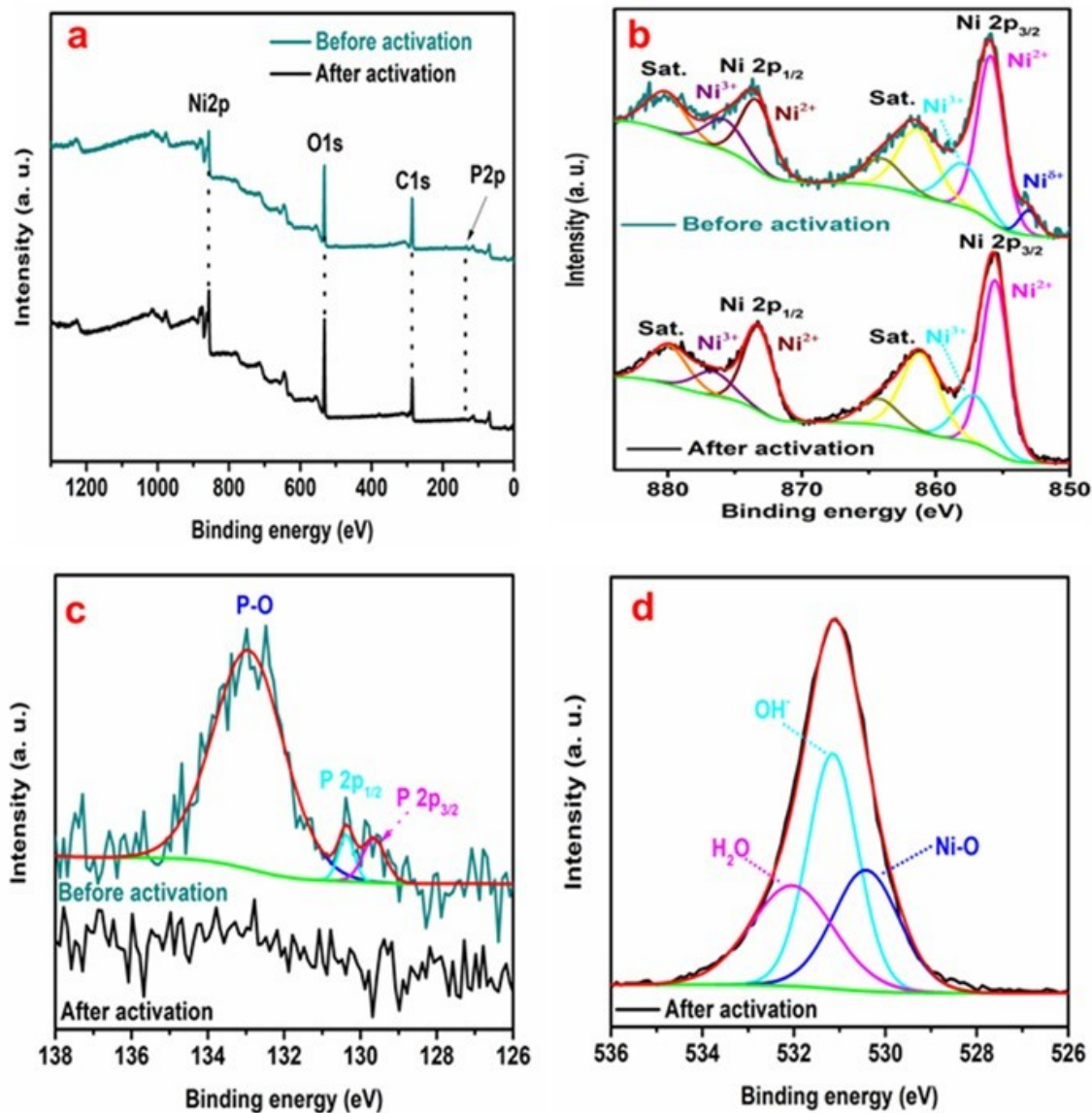


Fig. S12. XPS analysis of 10NiP@SS before and after activation: (a) XPS survey spectrum, (b) Ni 2p region, and (c) P 2p region.

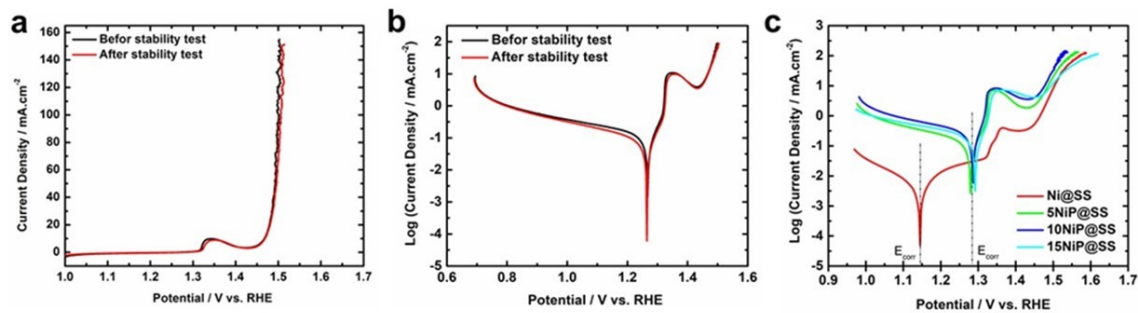


Fig. S13. a) LSV curves and b) Corrosion behavior for 10NiP@SS in 1M KOH solution before and after Chronopotentiometry stability test for 24h. c) Corrosion behavior for the as-prepared x NiP@SS electrodes and Ni@SS in 1M KOH.

Table S2. Comparison of the 10NiP@SS catalyst with recently published Ni phosphide- and SS-based catalysts for the OER in alkaline electrolytes.

Catalysts	Method of modification	Electrolyte	Overpotential (mv) at specific current density	Tafel plot (mV dec ⁻¹)	Ref.
10NiP@SS	Electrodeposition at room temperature	1 M KOH	238@10 271@100	41.42	This work
Ni@SS	Electrodeposition at room temperature	1 M KOH	274@10 338@100	42.82	
Bare SS	-	1 M KOH	321@10 427@100	71.02	
N, O-codoped nickel phosphide (NO/NiP@CP)	Hydrothermal process followed by pyrolysis under air and N ₂ atmospheres	1 M KOH	364@10	108.9	1
Hierarchical Ni-Co-P hollow nanobricks (HNBs)	Template-engaged strategy followed by sequential etching and phosphorization treatments	1 M KOH	270@10	76	2
Ni ₂ P/NF	Two-step hydrothermal-phosphorization process	1 M KOH	290@50 320@100	110	3
Fe, Mo- codoped Ni ₃ P	Electrodeposition	1 M KOH	250@0 290@100	-	4
Co ₃ O ₄ @Ni ₂ P-CoP/NF	Phosphating and carbonating Co ₃ O ₄ nanowires template-directed fabrication Ni-substituted ZIF-67 arrays onto a 3D Ni foam substrate.	1 M KOH	298@50	75	5
Mo-Ni ₃ S ₂ /Ni _x P _y	Solvothermal followed by phosphorization	1 M KOH	238@50	60.6	6
Mo-NiCoP	Hydrothermal followed by phosphorization	1 M KOH	269@10 364@100	76.7	7
Highly porous Ni-P	Electrodeposition	1 M KOH	279@10	39.5	8
OESSC	Acid etching followed by oxidizing by heating	1 M KOH	290@10	38.0	9

	and CH ₄ plasma treatment, respectively.				
Sulfurized stainless steel foil (SSFS)	Annealing process in presence of sulfur at 500 °C under Ar atmosphere.	1 M KOH	262@10	42.0	10
316 L SS ex situ-activated	Anodic dissolution of the 316 L metals followed by their possible precipitation in the 5 M LiOH electrolyte.	1 M KOH	300@10 330@100	42	11
N-doped surface-etched stainless-steel mesh (NESS)	Exfoliation method followed by annealing process at 400 °C	1 M KOH	278@10	83.0	12
Elox_SS	Thermal sulfurization in H ₂ S/Ar atmosphere at 500 °C followed by electrooxidation process in KOH	1 M KOH	267@10	77.1	13
Se-SS	Thermo-selenization followed by acid etching process.	1 M KOH	264@100	36	14
SSM-Ni-P (SSM= stainless steel mesh)	Chemical bath deposition of Ni followed by phosphorization under thermal decomposition	1 M KOH	223@10	43.0	15
N-doped anodized stainless-steel mesh (NASSM)	Anodic oxidation (4 °C, 10V) followed by nitrogenization (450 °C, NH ₃)	1 M KOH	225@10	49.7	16
434 SS scrubber	Direct use	1 M KOH	418@10	63	17
Stainless-steel fiber felt (SSFF)	Electrochemical induction with cyclic voltammetry (CV) in KOH solution	1 M KOH	230@10 279@100	44.0	18
CNT/SS	Atmospheric pressure chemical vapor deposition (APCVD) method		297@10	66.7	
OxCNT/SS	APCVD method followed by oxidation process in conc. H ₂ SO ₄ and conc. H ₂ SO ₄ solution containing	1 M KOH	267@10	44.0	19

	KMnO ₄ and NaNO ₃ at 40 °C				
RuO₂/O_xCNT/SS	APCVD method followed by oxidation process (in conc. H ₂ SO ₄ and conc. H ₂ SO ₄ solution containing KMnO ₄ and NaNO ₃ at 40 °C) and a hydrothermal process.		217@10	38.8	
Modified Ni42 steel	Anodization process	0.1 M KOH	254@10	71.6	20
		1 M KOH	215@10	-	
Modified AISI 316 steel	Hydrothermal combined in situ electrochemical oxidation–reduction cycle (EORC) method	1 M KOH	280@10	34	21
Ni _{0.33} Co _{0.67} S ₂ NN/SS	Two-step hydrothermal method		286@50	55	22
FeNi LDH@NWSSF	Non-woven stainless steel fabrics (NWSSF) were fabricated by wet lay-up papermaking process and followed by a heat treatment process and FeNi LDH@NWSSF was synthesized through a urea-assisted hydrothermal method on NWSSF.	1 M KOH	210@10	56	23
Modified AISI 304-12 h	Hydrothermal corrosion process in the presence of an equimolar mixture of KOH and NaOCl at 180 °C for 12 h.	1 M KOH	260@10	41.0	24
Fe(Ni)OOH modified SS	Oxidation process by immersing SS in an alkaline oxidant solution containing NaOH and (NH ₄) ₂ S ₂ O ₈ for 12 h	1 M KOH	300@10	34	25
NiS@SLS	Hydrothermal method	0.1 M KOH	297@11	47.0	26
Oxidized Steel	Oxidation process by	0.1 M	347@2	-	27

S235	chlorine gas	KOH			
Ni(Fe)O_xH_y/SS	Hydrothermal method at 100 °C	1 M KOH	230@20	36	28
Ni(OH)₂/316L stainless steel nanoparticles on Ni foam	Electrophoretic deposition (EPD) based co-deposition method	1 M KOH	220@10	42	29
Elox300-AISI 304	Anodization process at a current density of 1.77 A cm ⁻² in 7.2 M NaOH	1 M KOH	212@12	-	30
		0.1 M KOH	269@10	49	

Table S3. Comparison of overpotential at 10, 50 and 100 mA cm⁻² and R_{ct} for bare SS, Ni@SS, 5NiP@SS, 10NiP@SS, 15NiP@SS, 20NiP@SS and Pt-C@SS in case of HER.

Electrode	Overpotential		
	η_{10}	η_{50}	η_{100}
Bare SS	428	544	--
Ni@SS	376	496	--
5NiP@SS	288	378	--
10NiP@SS	285	366	423
15NiP@SS	268	348	403
20NiP@SS	277.5	366	424
Pt/C@SS	84	231	374

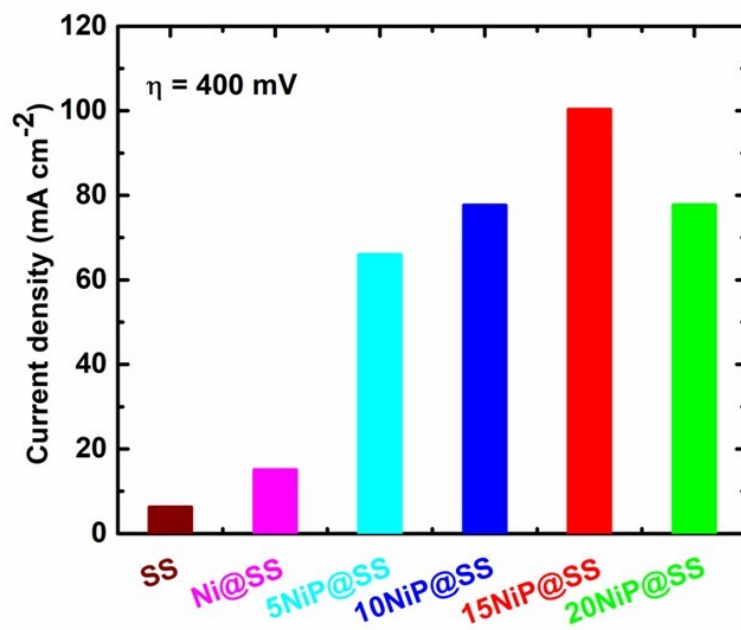


Fig. S14. Current densities for all prepared catalysts at an overpotential of 400 mV for HER.

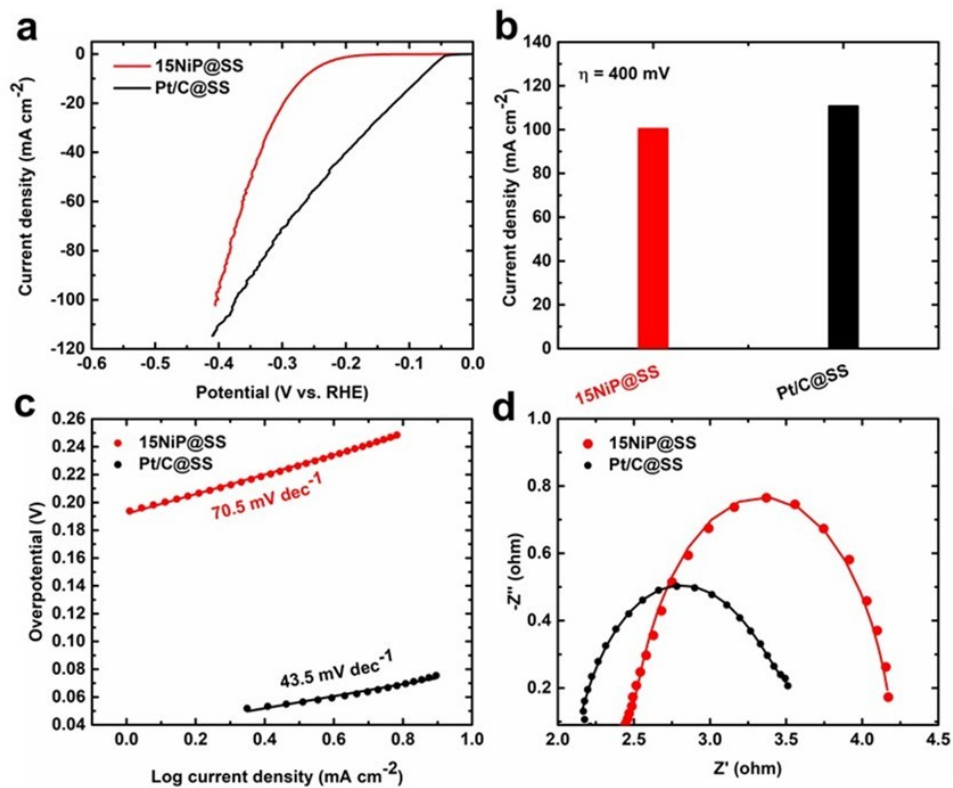


Fig. S15. HER electrocatalytic performance of Pt-C@SS and 15NiP@SS. a) LSV Polarization curves at 1 mV/s scan; b) Current densities at an overpotential of 400 mV; c) Tafel plots; d) Nyquist plots at -1.3 V vs. Hg/HgO.

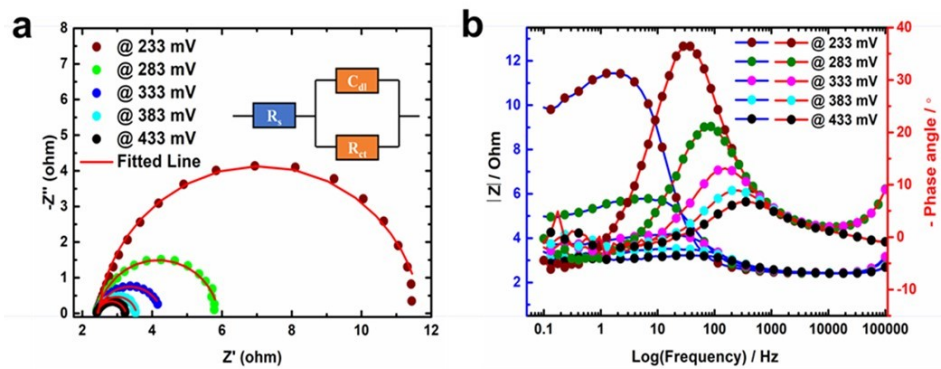


Fig. S16. a) Nyquist plots and b) Bode plots of 15NiP@SS electrode recorded at increasing overpotentials for HER.

Table S4: EIS data of HER on SS, Ni@SS and xNiP@SS electrodes .

Catalyst	R_s (Ohm)	R_{ct} (Ohm)	C_{dl} (F)	ECSA (cm ²)	Roughness factor (σ)
SS	2.29	23.06	2.07×10^{-04}	10.3	06.89
Ni@SS	2.16	10.32	2.27×10^{-04}	11.4	07.58
5NiP@SS	2.63	03.05	5.84×10^{-04}	29.2	19.50
10NiP@SS	2.17	02.36	5.93×10^{-04}	29.7	19.80
15NiP@SS	2.44	01.84	7.27×10^{-04}	36.4	24.20
20NiP@SS	2.19	02.39	5.99×10^{-04}	30.0	20.00

Table S5: EIS data of HER on 15NiP@SS electrode at different potentials.

@ Overpotential (vs. HER)	R_s (Ω)	R_{ct} (Ω)	C_{dl} (F)	ECSA (cm ²)	Roughness factor (σ)
233 mV	2.45	9.26	11.00×10^{-04}	55.1	36.7
283 mV	2.44	3.46	08.61×10^{-04}	43.0	28.7
333 mV	2.44	1.84	07.27×10^{-04}	36.4	24.2
383 mV	2.43	1.12	05.97×10^{-04}	29.9	19.9
433 mV	2.42	0.82	05.48×10^{-04}	27.4	18.3

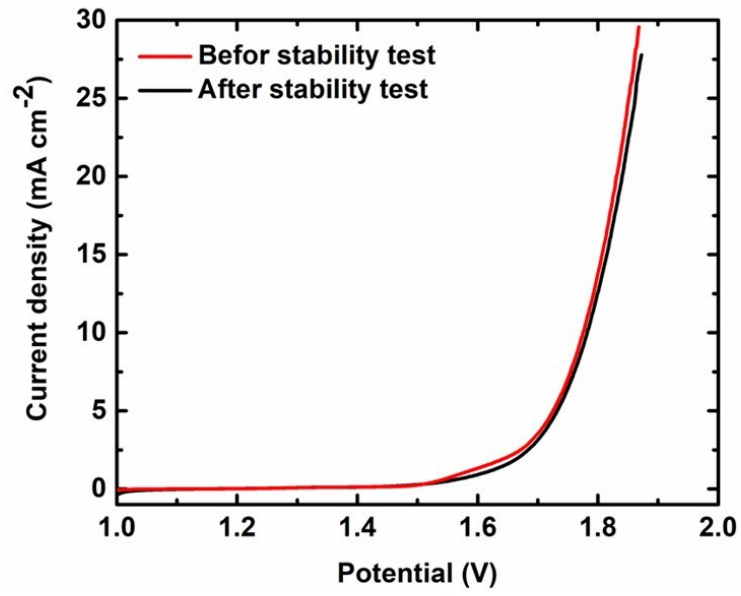


Fig. 17. Polarization curves of 15NiP@SS // 10NiP@SS couple before and after stability tests.

Table S6. Comparison of the 15NiP@SS catalyst with recently published Ni phosphide- and SS-based catalysts for the HER in alkaline electrolytes.

Catalysts	Method of modification	Electrolyte	Overpotential (mv) at specific current density	Tafel plot (mV dec ⁻¹)	Ref.
15NiP@SS	Electrodeposition at room temperature	1 M KOH	268 @10	70.5	This work
Ni@SS	Electrodeposition at room temperature	1 M KOH	376@10	109.63	
Bare SS	-	1 M KOH	428@10	117.93	
Ni ₂ P/CNS	Pyrolysis process followed by hydrothermal process	0.1 M KOH	315@10	120	31
Ni ₂ P/Ni ₁₂ P ₅	Hydrothermal method at 140 °C	1 M KOH	234@10	98	32
Ni ₁₂ P ₅			248@10	100	
Ni ₂ P			258@10	169	
Ni ₃ P	Pyrolysis process at 700 °C for 24 h	1 M NaOH	291@10	119	33
Ni ₂ P nanoparticles	Thermal reaction of NaH ₂ PO ₂ and NiCl ₂ ·6H ₂ O at 250 °C	1 M KOH	250@10	100	34
Ni ₂ P film	Deposition of nickel layer using a Semicore electron-beam evaporator followed by phosphorization process	1 M KOH	200@10	-	35
NiFeP			255@10		
FeP			300@10		
NiFe LDH-NS@defective graphene	Exfoliation followed by electrostatic flocculation	1 M KOH	300@10	-	36
EG/Co _{0.85} Se/NiFe-LDH	Two hydrothermal process	1 M KOH	~265@10	160	37
CoNi ₂ S ₄	Hydrothermal method	1 M KOH	280@10	85	38
Modified Ni42 steel	Anodization process	1 M KOH	299@10	117.5	20
SS scrubber	Direct use	1 M KOH	373@10	121	17
Ni _{0.33} Co _{0.67} S ₂ NN/SS	Two-step hydrothermal method	1 M KOH	350@30	76	22
N, P doped SS316L	Exfoliation method followed by annealing	1 M KOH	230@10		12

process at 400 °C					
Etched SS304 (ESS)	Immersing process in 1 M HCl solution at 60 °C for 1.5 h.	1 M KOH	466 @10	-	39
Pristine anodized SS304 (EASS)	Etching process in HCl followed by anodization process		370 @10	-	
Activated anodized SS304 (EASS-Ar/H ₂)	Etching process in HCl followed by anodization process and thermal annealing process in Ar/H ₂ at 650 °C for 1 h		244 @10	-	
CNT/SS	Atmospheric pressure chemical vapor deposition (APCVD) method	1 M KOH	334@10	119.6	19
OxCNT/SS	APCVD method followed by oxidation process in conc. H ₂ SO ₄ and conc. H ₂ SO ₄ solution containing KMnO ₄ and NaNO ₃ at 40 °C		257@10	105.6	

Table S7. Comparison of the overall water splitting performance for the 10NiP@SS (+) || 15NiP@SS (-) catalyst with recently published Ni phosphide- and SS-based catalysts in alkaline electrolytes.

Catalysts	Method of modification	Electrolyte	Overpotential (mv) at 10 mA cm ⁻²	Ref.
10NiP@SS (+) 15NiP@SS (-)	Electrodeposition at room temperature	1 M KOH	1.77	This work
NiS/Ni ₂ P (+) NiS/Ni ₂ P (-)	Hydrothermal followed by sulfurization and phosphorization	1 M KOH	1.67	40
C@Ni ₈ P ₃ (+) C@Ni ₈ P ₃ (-)	solvothermal procedure	1 M KOH	1.65	41
Ni ₈ P ₃ (+) Ni ₈ P ₃ (-)			1.79	
Ni ₅ P ₄ @ Ni foil (+) Ni ₅ P ₄ @ Ni foil (-)	Heating of nickel foil and red phosphorus for 1 h at 550 °C under an inert atmosphere	1 M KOH	1.7@10	42
Ni ₂ P/Ni(PO ₃) ₂ (+) Ni ₂ P/Ni(PO ₃) ₂ (-)	Hydrolysis process followed by pyrolysis and phosphorization	1 M KOH	1.63	43
Ni-P/CF (+) Ni-P/CF (-)	Electrodeposition	1 M KOH	1.68	44
Ni ₂ P/NF (+) Ni ₂ P/NF (-)	Thermal reaction of NaH ₂ PO ₂ and NiCl ₂ ·6H ₂ O at 250 °C	1 M KOH	1.63	45
NESS (+) NESSP (-)	Exfoliation method followed by annealing process at 400 °C	1 M KOH	1.74	12
SS scrubber (+, -)	Direct use	1 M KOH	1.98	17
CNT/SS (+, -)	Atmospheric pressure chemical vapor deposition (APCVD) method	1 M KOH	1.95	19
OxCNT/SS (+, -)	APCVD method followed by oxidation process in conc. H ₂ SO ₄ and conc. H ₂ SO ₄ solution containing		1.83	
NASSM (+, -)	Anodic oxidation (4 °C, 10V) followed by nitrogenization (450 °C, NH ₃)	1 M KOH	1.61	16
Ni _{0.33} Co _{0.67} S ₂ NN/SS	Two-step hydrothermal method	1 M KOH	1.67	22
FeNi LDH@NWSSF	Non-woven stainless steel fabrics (NWSSF) were fabricated by wet lay-up papermaking process and	1 M KOH	1.56	23

followed by a heat treatment process and FeNi LDH@NWSSF was synthesized through a urea-assisted hydrothermal method on NWSSF.			
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Video S2: Hydrogen and oxygen production during the full water splitting test at 10 mA cm^{-2} .

Video S3: Hydrogen and oxygen production during the full water splitting test at 20 mA cm^{-2} .

Video S4: Hydrogen and oxygen production during the full water splitting test at 50 mA cm^{-2} .

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